

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	5481	((430/296,942) or (250/492.3)).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/08/14 10:26
S2	413	S1 and draw\$4 same (circ \$4 or circul\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2007/08/14 10:32
S3	210	S1 and draw\$4 with (circ \$4 or circul\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2007/08/14 10:34
S4	26	S1 and draw\$4 with (circ \$4 or circul\$4) and concent\$4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2007/08/14 10:43
S5	15	S1 and draw\$4 with (circ \$4 or circul\$4) and concent\$4 and @ad<"20030323"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2007/08/14 10:45
S6	1	(US-7034319-\$).did.	USPAT	ADJ	ON	2007/08/14 12:36
S7	1	("4467211").PN.	USPAT	OR	OFF	2007/08/14 13:35
S9	9897	(250/492.1-492.3).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/05/07 13:35
S10	967	(250/492.22).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/05/07 13:35

S11	20039	((charg\$4 particle) or ion or electron or particle) with beam with (lithograph\$4 or photo?lithograph\$4 or photolithograph\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/05/07 13:36
S12	7533	((charg\$4 particle) or ion or electron or particle) with beam with (lithograph\$4 or photo?lithograph\$4 or photolithograph\$4) and (specimen or sample or surface or film or target or substrate or subject or workpiece or article or object or wafer) with (rotat\$4 or turn\$4 or spin\$4 or revolv\$4 or translat\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/05/07 13:39
S13	7126	((charg\$4 particle) or ion or electron or particle) with beam with (lithograph\$4 or photo?lithograph\$4 or photolithograph\$4) and (specimen or sample or surface or film or target or substrate or subject or workpiece or article or object or wafer) with (rotat\$4 or turn\$4 or spin\$4 or revolv\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/05/07 14:29
S14	197	((charg\$4 particle) or ion or electron or particle) with beam with (lithograph\$4 or photo?lithograph\$4 or photolithograph\$4) and (specimen or sample or surface or film or target or substrate or subject or workpiece or article or object or wafer) with (rotat\$4 or turn\$4 or spin\$4 or revolv\$4) and concentric\$4 with (elliptic\$4 or oval or round\$4 or circl\$4 or circula\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/05/07 14:31

S15	140	@ad<"20050322" and ((charg\$4 particle) or ion or electron or particle) with beam with (lithograph\$4 or photo?lithograph\$4 or photolithograph\$4) and (specimen or sample or surface or film or target or substrate or subject or workpiece or article or object or wafer) with (rotat\$4 or turn\$4 or spin\$4 or revolv\$4) and concentric\$4 with (elliptic\$4 or oval or round\$4 or circl\$4 or circula\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/05/07 15:25
S16	122	@ad<"20050322" and (electron) with beam with (lithograph\$4 or photo? lithograph\$4 or photolithograph\$4) and (specimen or sample or surface or film or target or substrate or subject or workpiece or article or object or wafer) with (rotat\$4 or turn\$4 or spin\$4 or revolv\$4) and concentric\$4 with (elliptic\$4 or oval or round\$4 or circl\$4 or circula\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/05/07 15:26
S17	25	@ad<"20050322" and (electron) with beam with (lithograph\$4 or photo? lithograph\$4 or photolithograph\$4) and (specimen or sample or surface or film or target or substrate or subject or workpiece or article or object or wafer) with (rotat\$4 or turn\$4 or spin\$4 or revolv\$4) and concentric\$4 with (elliptic\$4 or oval or round\$4 or circl\$4 or circula\$4) and deflect\$4 with beam	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/05/07 15:53

S18	4	@ad<"20050322" and (electron) with beam with (lithograph\$4 or photo? lithograph\$4 or photolithograph\$4) and (specimen or sample or surface or film or target or substrate or subject or workpiece or article or object or wafer) with (rotat\$4 or turn\$4 or spin\$4 or revolv\$4) and concentric\$4 with (elliptic\$4 or oval or round\$4 or circl\$4 or circula\$4) and deflect\$4 with beam and (synchroniz\$4 or synchronizat\$4 or sync\$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/05/07 18:40
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5/ 8/ 2008 2:09:48 PM

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